

TECHNICAL DATA SHEET



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PRODUCT

VELVET ABRASIVE PASTE polishing (C7124, C7125, C7126)

FEATURES

VELVET ABRASIVE PASTE polishing is formulated using synthetic waxes and metal oxides. It is excellent to remove small scratches and stains from all types of bodywork paints even if oxidated. It does not contain silicones or asbestos.

It is ideal to remove the paintings opacity or for car finishing before delivery; easy application and excellent results are its characteristics.

Thanks to the two versions: fine grain (C7124) and medium grain (C7126), it is possible to work on any kind of scratch even the deepest one, in the optimal way for granting the best result.

Available in two versions: solvent-base and water-base (C7125).

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	Solvent-based	Water-based	
Specific weight	1440 ± 20 g/l	1060 ± 20 g/l	(MI 001)
Aspect	Homogeneous paste	Homogeneous paste	
Colour	White	White	

STORAGE

Keep the container well closed and stored in a cool (temperature below 25°C) and ventilated environment for a maximum period of 12 months from the date of production marked on the tin. Avoid direct sun exposure.

SAFETY RULES

Keep the room ventilated during application and drying processes. During application, the use of personal protective equipment is recommended. Carefully read the safety data sheet before application.

APPLICATION

- Make sure that the surfaces to be treated are completely dry and clean;
- Apply VELVET ABRASIVE PASTE directly onto the surface to be treated;
- Polish it using a polishing sponge and an angle grinder at variable speed by adopting a medium speed;
- Refinish the previously treated surface using a wool disk;
- The mixture of hydrocarbon solvents confers an adequate drying speed that makes its use easier and permits an immediate polish; at the same time it is possible to polish large areas without running the risk it becomes difficult to remove.

ADDITIONAL INFORMATION

Note: In case of excessive thickening add petroleum or gas oil and mix carefully. Processing should not take place under the direct sun exposure.